

**substance:  $\text{Mn}_n\text{Si}_{2n-m}$**

**property: general characterization**

The  $\text{Mn}_n\text{Si}_{2n-m}$  phases form by a peritectic reaction around 1550°C [66M] (earlier interpreted as congruent melting [64F]). In most cases the exact stoichiometry of the samples was not determined. Many samples probably contained a mixture of different  $\text{Mn}_n\text{Si}_{2n-m}$  phases as well as traces of metallic and paramagnetic MnSi [73L].  $\text{Mn}_4\text{Si}_7$  is metastable below 1125°C. On slow cooling it decomposes into  $\text{MnSi}_{1.73}$  + interstitial Si. If all valence electrons are bonded in  $\text{Mn}_4\text{Si}_7$ , the interstitial silicon in the low temperature phase should act as an acceptor. This assumption is supported by the fact that the experimental hole density ( $4.6 \cdot 10^{20} \text{ cm}^{-3}$ ) is roughly equal to the number of Frenkel defects ( $6.5 \cdot 10^{20} \text{ cm}^{-3}$ ) [72U].

Reports on the magnetic properties of the  $\text{Mn}_n\text{Si}_{2n-m}$  phases are contradictory. According to [70M, 73L] the pure  $\text{Mn}_n\text{Si}_{2n-m}$  phases (all?) should be diamagnetic, but other authors report on antiferromagnetism [66S, 80N] and Curie-Weiss behavior [65R].

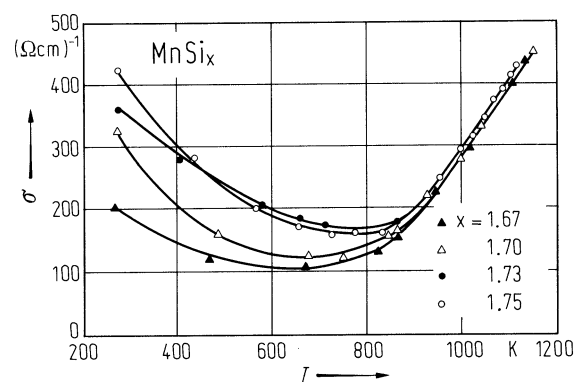
Electrical conductivity, Seebeck coefficient and thermal conductivity for different Si concentrations: Figs. 1...4.

## References:

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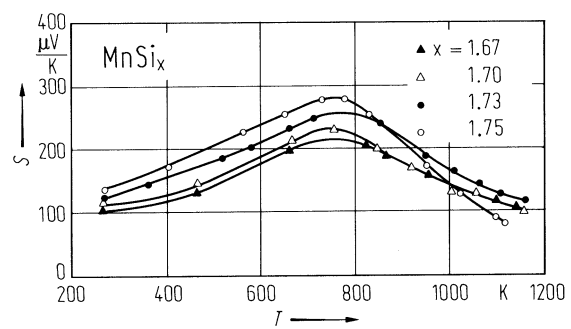
**Fig. 1.**

$\text{MnSi}_x$ . Electrical conductivity vs. temperature for polycrystalline samples [72U].



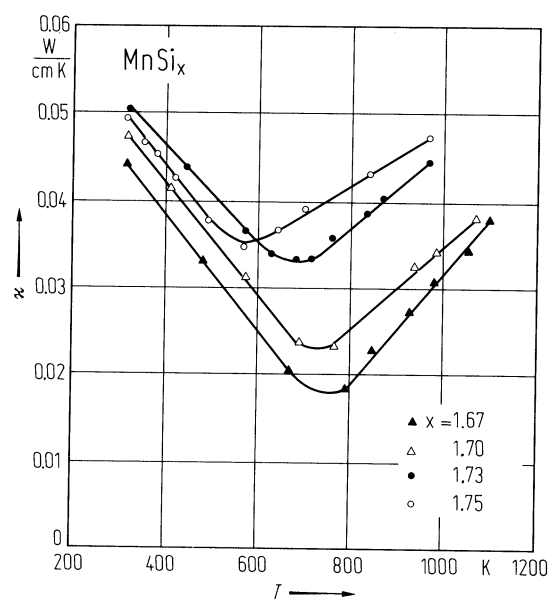
**Fig. 2.**

$\text{MnSi}_x$ . Thermoelectric power vs. temperature for polycrystalline samples [72U].



**Fig. 3.**

$\text{MnSi}_x$ . Thermal conductivity vs. temperature for polycrystalline samples [72U].



**Fig. 4.**

$\text{Mn}_n\text{Si}_{2n-m}$ . Electrical conductivity and Seebeck coefficient vs. temperature for polycrystalline samples [61K]. Open symbols;  $\text{MnSi}_{1.735}$  (47 wt% Si); full symbols:  $\text{MnSi}_{1.770}$  (47.5 wt% Si).

